	Application No.	Applicant(s)
	Application No.	Apprount(s)
Notice of Allowability	10/501,813	NARITA ET AL.  Art Unit
Notice of Anowability	Examiner	Artonit
	Edna Wong	1795
The MAILING DATE of this communication appear All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI	(OR REMAINS) CLOSED in this app or other appropriate communication IGHTS. This application is subject to	olication. If not included will be mailed in due course. THIS
1. This communication is responsive to <u>Appeal Brief dated No.</u>	ovember 5, 2007.	
2. The allowed claim(s) is/are 1,2 and 6.		
<ul> <li>3.  Acknowledgment is made of a claim for foreign priority ur</li> <li>a)  All b)  Some* c)  None of the:</li> <li>1.  Certified copies of the priority documents have</li> </ul>		
2. Certified copies of the priority documents have been received in Application No		
3. \( \sum \) Copies of the certified copies of the priority documents have been received in this national stage application from the		
International Bureau (PCT Rule 17.2(a)).		
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		complying with the requirements
4. A SUBSTITUTE OATH OR DECLARATION must be subminFORMAL PATENT APPLICATION (PTO-152) which give		
5. CORRECTED DRAWINGS ( as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached		
1)  hereto or 2)  to Paper No./Mail Date		
(b) including changes required by the attached Examiner' Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t	i.84(c)) should be written on the drawing the header according to 37 CFR 1.121(c	ngs in the front (not the back) of d).
6. DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT		
Attachment(s)	, <b>,</b> , , , , , , , , , , , , , , , , ,	
1. Notice of References Cited (PTO-892)	5. Notice of Informal P	• •
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary Paper No./Mail Dat	
3. Information Disclosure Statements (PTO/SB/08), Paper No./Mail Date	7.   Examiner's Amendr	ment/Comment
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. 🛛 Examiner's Stateme	ent of Reasons for Allowance
	9.	
		Sincular
		EDNA WONG PRIMARY EXAMINER

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## REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance:

Claims 1-2 and 6 are allowable over the prior art of record because the prior art does not teach or suggest a method for forming a high-Re-content alloy film which contains Re at 98% or more by atomic composition, said method comprising the step of performing an electroplating process as presently claimed, esp., forming a high-Recontent alloy film which contains <u>Re at 98% or more</u> by <u>atomic</u> composition wherein the aqueous solution includes at least one of a <u>Li ion or Na ion, in total concentration of 0.0001 to 5.0 mol/L.</u>

The prior art does not contain any language that teaches or suggests the above. Castonguay and Phillips fail to teach forming a high-Re-content alloy film which contains Re at 98% or more by atomic composition wherein the aqueous solution includes at least one of a Li ion or Na ion, in total concentration of 0.0001 to 5.0 mol/L. Therefore, a person skilled in the art would not have been motivated to adopt the above conditions, and a prima facie case of obviousness cannot be established.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the

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examiner should be directed to Edna Wong whose telephone number is (571) 272-1349. The examiner can normally be reached on Mon-Fri 7:30 am to 4:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam Nguyen can be reached on (571) 272-1342. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Edna Wong
Primary Examiner
Art Unit 1795

EW November 28, 2007